

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	36565	ald or (atomic adj layer adj deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 13:35
L3	2641	I2 and catalyst	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 13:36
L4	242	I3 and (sio or (silicon adj dioxide))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 13:36
L5	136	I4 and oxygen	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 13:36
L6	67	I5 and anneal\$	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/12/21 13:37